Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	564	(438/758).CCLS.	USPAT	OR	OFF	2004/12/02 15:40
L2	1587	semiconductor and (silicon adj oxide) and film and ammonia and (hydrogen adj peroxide) and nitrid$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/02 15:42
L3	944	semiconductor and (silicon adj oxide) and film and ammonia and (hydrogen adj peroxide) and nitrid$	USPAT	OR	ON	2004/12/02 15:42
L4	84	semiconductor and (silicon adj oxide) and film and ammonia and (hydrogen adj peroxide) and nitriding	USPAT	OR	ON	2004/12/02 15:42
L5	63	semiconductor and (silicon adj oxide) and ammonia and (hydrogen adj peroxide) and (nitriding with film)	USPAT	OR	ON	2004/12/02 15:43
L6	21	semiconductor and (silicon adj oxide) and (ammonia adj gas) and (hydrogen adj peroxide) and (nitriding with film)	USPAT	OR	ON	2004/12/02 16:57
L7	3	(("6032801") or ("5579686") or ("5441154")).PN.	USPAT	OR	OFF	2004/12/02 15:50
L8	1127	(438/622).CCLS.	USPAT	OR	OFF	2004/12/02 16:57
L9	774	(438/618).CCLS.	USPAT	OR	OFF	2004/12/02 16:58
L10	1063	(438/624).CCLS.	USPAT	OR	OFF	2004/12/02 16:58